

# PM5

Cost-effective, manual wafer probing

## Chuck

- Dedicated 150 mm chucks for general purpose, RF, mmW and triaxial measurements and high temperatures up to 400 °C available
- Excellent planarity

## Positioner

- Fits with all Cascade Microtech positioners down to submicron positioning capability
- Various probe arms for accurate I-V, C-V and RF measurements available

## Probe platen

- Compatible with probe card adapters
- Probe cards and positioners can be used simultaneously
- Large space to fit several positioners on each side
- Optimized RF platen for RF, mmW, load-pull and RF noise applications
- Cooled platen for chucks up to 300 °C

## Chuck theta movement

- 360° theta for easy alignment
- Fine theta movement option for exact RF probe tip alignment

## Platen movement

- 40 mm travel range for maximum flexibility
- System height can adapt easily from wafer to package board application

## Platen separation

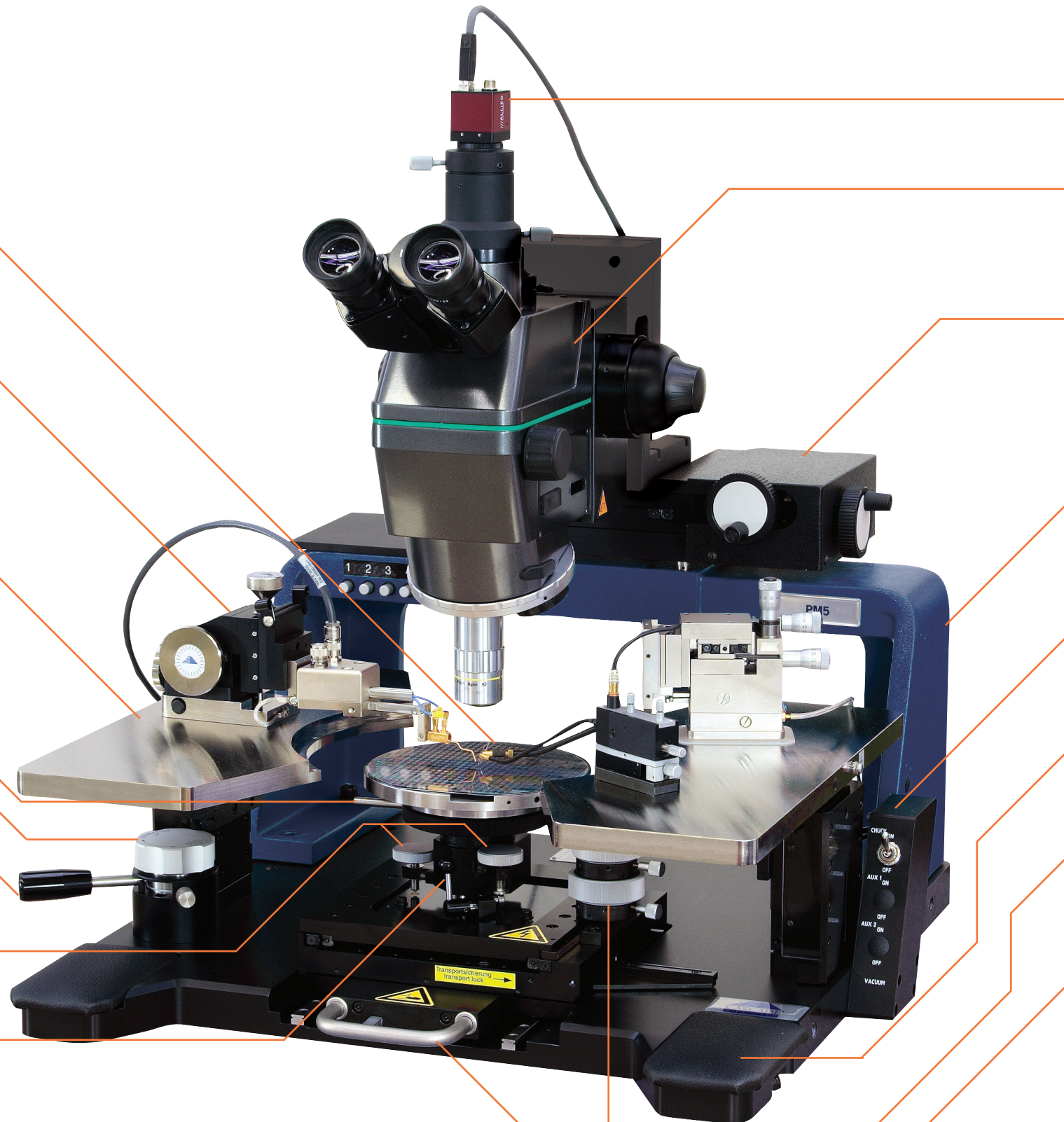
- 200 µm separation drive with 1 µm precision repeatable movement to contact position

## Chuck Z movement

- 10 mm adjustment range for precise wafer height adjustment

## Chuck Z-separation movement

- Adjustable 3 mm chuck Z movement for simple and safe wafer loading



## Camera

- C-mount camera for simple navigation and documentation

## Microscope

- High-resolution microscopes (eVue™/iVista™ LC, FS70, PSM1000) for work on small features, even with laser cutter option
- Stereo microscopes for easy work with RF probe tips

## Microscope movement

- 150 mm x 100 mm manual movement for large area evaluation
- 50 mm x 50 mm high resolution movement for precise work with >20x objectives
- 50 mm x 50 mm motorized movement for easy navigation and heavy duty microscope integration

## Microscope bridge

- Cast bridge for maximum microscope stability and low drift
- Low profile design for ergonomic microscope operation
- Alternate boom stand for stereo microscope available

## Vacuum switches

- Separate switches for main chuck vacuum and up to two calibration substrates

## Base platen

- Small footprint fits into small housings like glove boxes
- Easy operation of chuck and platen drives with convenient hand rest

## Chuck X-Y-movement

- Precise movement allows chuck positioning with < 5 µm resolution
- Coaxial knobs for one hand operation of both axes
- Separate axis fixation for easy navigation along lines

## Chuck roll-out

- 90 mm roll-out for easy wafer load, even with built-in probe card

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